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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Wu et al.

Application No.: 10/820,525

Filed: April 7, 2004

Title: METHODS FOR PRODUCING LOW-K CDO FILMS WITH LOW RESIDUAL STRESS

Attorney Docket No.: NOVLP091

Examiner: Not Yet Assigned

Group: 2812

Confirmation No.: 8337

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as first-class mail on February 27, 2006 in an envelope addressed or Mail Stop Amendment, Commissioner for Patents, P.O. Box 450, Aexandria, VA 22313-1450.

Signed:

Tara Hayden

INFORMATION DISCLOSURE STATEMENT 37 CFR §§1.56 AND 1.97(b)

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

The references listed in the attached PTO Form 1449, copies of which are attached, may be material to examination of the above-identified patent application. Applicants submit these references in compliance with their duty of disclosure pursuant to 37 CFR §§1.56 and 1.97. The Examiner is requested to make these references of official record in this application.

This Information Disclosure Statement is not to be construed as a representation that a search has been made, that additional information material to the examination of this application does not exist, or that these references indeed constitute prior art.

This Information Disclosure Statement is: (i) filed within three (3) months of the filing date of the above-referenced application, (ii) believed to be filed before the mailing date of a first Office Action on the merits, or (iii) believed to be filed before the mailing of a first Office Action after the filing of a Request for Continued Examination under §1.114. Accordingly, it is believed that no fees are due in connection with the filing of this Information Disclosure Statement. However, if it is determined that any fees are due, the Commissioner is hereby authorized to charge such fees to Deposit Account 500388 (Order No. NOVLP091).

Respectfully submitted,

BEYER WEAVER & THOMAS, LLP

Denise S. Bergin

Registration No. 50,581

Denise By

P.O. Box 70250 Oakland, CA 94612-0250 Form 1449 (Modified)

Information Disclosure

Statement By Applicant

(Use Several Sheets if Necessary)

Atty Docket No. Application No.:

NOVLP091

Applicant:

Wu et al.

Filing Date

04-07-2004

Group

2812

U.S. Patent Documents

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Examiner						Sub-	Filing
Initial	No.	Patent No.	Date	Patentee	Class	class	Date
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Foreign Patent or Published Foreign Patent Application

Examiner		Document	Publication	Country or		Sub-	Trans	lation
Initial	No.	No.	Date	Patent Office	Class	class	Yes	No

Other Documents

Examiner		,		
Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication		
	C1	U.S. Office Action mailed December 27, 2005, from U.S Application No. 10/789,103		
		[Atty Dkt No. NOVLP094/NVLS-002919].		
	C2	U.S. Office Action mailed December 23, 2005, from U.S Application No. 10/800,409		
		[Atty Dkt No. NOVLP098/NVLS-002907].		
	C3	U.S. Office Action mailed February 7, 2006, from U.S Application No. 10/672,305		
		[Atty Dkt No. NOVLP069/NVLS-000821].		
	C4	U.S. Office Action mailed December 20, 2005, from U.S Application No. 10/672,311		
		[Atty Dkt No. NOVLP075/NVLS-000820].		
	C5			
		[Atty Dkt No. NOVLP083/NVLS-2867].		
	C6	U.S. Office Action mailed January 9, 2006, from U.S Application No. 10/785,235		
1		[Atty Dkt No. NOVLP085/NVLS-2875].		
Examiner	•	Date Considered		

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.